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FORM PTO-1449	SERIAL NO. Not yet assigned	CASE NO. 10808/200
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT	FILING DATE Herewith	GROUP ART UNIT Not yet assigned
(use several sheets if necessary)	APPLICANT(S): Hin-Yiu Chung et al.	

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS/ SUBCLASS	TRANSLATION YES OR NO
MDH/	GB 2 355 850 A <small>Number-Kind Code (if known)</small>	May 2, 2001	United Kingdom		
↓	A9 WO 99/03141	January 21, 1999	WO		
	A10 GB 2 295 271 A	May 22, 1996	United Kingdom		
	A11 DE 689 19 408 T2	September 29, 1989	Germany		
	A12 DE 37 50 382 T2	March 4, 1987	Germany		

**EXAMINER
INITIAL**

OTHER ART - NON PATENT LITERATURE DOCUMENTS

(Include name of author, title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date page(s), volume-issue number(s), publisher, city and/or country where published.)

/MDH/	A13	Spezialgraphit von SGL Carbon, Produkte für die Halbleitertechnik, SGL Carbon Group, pgs. 2-17, March 2001
	A14	H.Q. Jia, H. Chen, W.C. Wang, W.X. Wang, W. Li, Q. Huang and Junming Zhou, <i>The Study of Thermal Stability During Wet Oxidation of Al/Si</i> , Institute of Physics, Chinese Academy of Sciences, pgs. 484-488, <i>Journal of Crystal Growth</i> , Vol. 223, Issue 4, March 2001.
	A15	William G. Breiland, Michael E. Coltrin, J. Randall Creighton, Hong Q. Hou, Harry K. Moffat and Jeffrey Y. Tsao, <i>Organometallic Vapor Phase Epitaxy</i> , Center for Compound Semiconductor Science and Technology, Sandia National Laboratories, Materials Science and Engineering: R. Reports, Vol. 24, Issue 6, pgs. 241-274, February 1999.
	A16	Copy of International Search Report from International Application Number PCT/DE/02523. 1/
	A17	Copy of Examination Report from International Application Number PCT/DE/02523. 1/26/03

EXAMINER /Monica D. Harrison/	DATE CONSIDERED 06/22/2009
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /MDH.